

## Band Gap Engineering in Hexagonal Bilayer Boron Nitride: A Tight-binding Study

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**Abstract.** We address here the electronic band dispersion and density of states of AB stacked bilayer boron nitride in a transverse applied electric field. The system is described by kinetic energy with nearest neighbor electron-hopping with hopping energy  $t_1$  and gate potential  $V$  across for both the layers. The electron Green's functions are calculated by Zubarev's Green's function technique and electron band dispersion is found by equating the denominator of the Green's function to zero. Finally density of states is calculated from the imaginary part of the Green's function and results are interpreted by varying the different physical parameters of the system.

**Keywords.** Band energy dispersion, Density of states, AB- stacked bilayer BN

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